



## U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

Information Disclosure  
Statement

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## U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date
<u>lm</u>	6218301	04/17/01	Yoon et al.	438	685	07/31/00

lm FOREIGN PATENT OR PUBLISHED FOREIGN PATENT APPLICATION

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Title: Chemical Vapor Deposition of Diamond Coatings on Hard Substrates

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

lm a.K.K. Lai and H.H. Lamb. Tungsten Chemical Vapor Deposition Using Tungsten Hexacarbonyl: Microstructure of As-Deposited and Annealed Films. Thin Solid Films, Vol. 370, No. 1-2, pgs. 114-121 (2000).

b.

c.

d.

e.

Examiner VLS Date Considered 04-15-03  
EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Substitute Disclosure Form (PTO-1449)

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